

## The main tasks of designing a secure network-on-chip

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## Abstract

The main tasks in the initial design of the network on chip, ensuring of information security. Some peculiarities.

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Today micro-electronic products are influencing the ways of communication, learning and entertainment[1]. The key driving force for the developments during decades is the System-on-Chip (SoC) technologies, where complex applications are integrated onto single ULSI(Ultra Large Scale Integration) chips. Not only functionally enriched, these products such as mobile phones, notebooks and personal handheld sets are becoming faster, smaller-in-size, larger-in-capacity, lighter-in-weight, lower-in-power-consumption and cheaper. One could favorably think that this trend will persistently continue. Following this trend, we could integrate more and more complex applications and even systems onto a single chip. However, our current methodologies for SoC design and integration do not evenly advance due to the big challenges confronted. NETWORK-ON-CHIP (NoC) has been proposed as a solution for on-chip communication challenges for future multiprocessor system-on chip (MPSoC) architectures[1-4]. Each computation or storage core interacts with the NoC through a resource-to-network interface. The NoC supports packet-switching-based communication across multiple clock domains (or islands). NoC is inherently scalable and supports high bandwidth by enabling concurrent communication(on Figure).



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Deep SubMicron (DSM) effects [1]: In early days of VLSI design, signal integrity effects such as interconnect delay, crosstalk, inter-symbol interference, substrate coupling, transmission-line effects, etc. were negligible due to relatively slow clock speed and low integration density. Chip interconnect was reliable and robust. At the scale of 250nm with aluminum and 180nm with copper and below, interconnect started to become a dominating factor for chip performance and robustness. As the transistor density is increased, wires are getting neither fast nor reliable. More noise sources due to inductive fringing, crosstalk and transmission line effects are coupled to other circuit nodes globally on the chip via the substrate, common return ground and electromagnetic interference. More and more aggressive use of high-speed circuit families, for example, domino circuitry, scaling of power supply and threshold voltages, and mixed-signal integration combine to make the chips more noise-sensitive. Third, higher device densities and faster switching frequencies cause larger switching-currents to flow in the power and ground networks. Consequently, power supply is plagued with excessive IR voltage drops as wells as inductive voltage drops over the power distribution network and package pins. Power supply noise degrades not only the driving capability of gates but also causes possible false switching of logical gates. Today signal and power integrity analysis is as important as timing, area and power analysis.

Global synchrony [1,2]: Predominating digital IC designs have been following a globally synchronous design style where a global clock tree is distributed on the chip, and logic blocks function synchronously. However, this style is unlikely to survive with future wire interconnect. The reason is that technology scaling does not treat wire delay and gate delay equally. While gate delay (transistor switching time) has been getting dramatically smaller in proportion to the gate length, wires have slowed down. As the chip becomes communication-bound at 130 nm, multiple cycles are required to transmit a signal across its diameter. As estimated in, with the process technology of 35 nm in year 2014, the latency across the chip in a top-level metal wire will be 12 to 32 cycles depending on the clock rate assuming best transmission conditions such as very low-permittivity dielectrics, resistivity of pure copper, high aspect ratio (ratio of wire height to wire width) wires and optimally placed repeaters. Moreover, a clock tree is consuming larger portions of power and area budget and clock skew is claiming an ever larger portion of the total cycle time [1]. Even if we have an unlimited number of transistors on a chip, chip design is to be constrained by communication rather than capacity. A future chip is likely to be partitioned into locally synchronous regions but global communication is asynchronous, so called GALS (Globally Asynchronous Locally Synchronous)

Communication architecture [1,2]: Most current SoCs have a bus-based architecture, such as simple, hierarchical or crossbar-type buses. In contrast to the scaling of chip capacity, buses do not scale well with the system size in terms of bandwidth, clocking frequency and power. First, a bus system has very limited concurrent communication capability since only one device can drive a bus segment at a time. Current SoCs integrate fewer than five processors and, rarely, more than 10 bus masters. Second, as the number of clients grows, the intrinsic resistance and capacitance of the bus also increase. This means that the bus speed is inherently difficult to scale up. Third, a bus is inefficient in energy since every data transfer is broadcast. The entire bus wire has to be switched on and off. This means that the data must reach each receiver at great energy cost. Although improvements such as split-transaction protocols and advanced arbitration schemes for buses have been proposed, these incremental techniques can not overcome the fundamental problems. To explore the future chip capacity, for high-throughput and low-power applications, hundreds of processor-sized resources must be integrated. A bus-based architecture would become a critical performance and power bottleneck due to the scalability problem. Novel on-chip communication architectures are desired.

Power and thermal management [1]: As circuits run with higher and higher frequencies, lowering power consumption is becoming extremely important. Power is a design constraint, which is no more subordinate to performance. Despite process and circuit improvements, power consumption shows rapid growth. Equally alarming is the growth in power density on the chip die, which increases linearly. In face of DSM effects, reducing power consumption is becoming even more challenging. As devices shrink to submicron dimensions, the supply voltage must be reduced to avoid damaging electric fields. This development, in turn, requires a reduced threshold voltage. However, leakage current increases exponentially with a decrease in the threshold voltage. In fact, a 10% to 15% reduction can cause a two-fold increase in leakage current. In increasingly smaller devices, leakage will become the dominant source of power consumption. Further, leakage occurs as long as power flows through the circuit. This constant current can produce an increase in the chip temperature, which in turn causes an increase in the thermal voltage, leading to a further increase in leakage current.

Verification [1-3]: Today SoC design teams are struggling with the complexity of multimillion gate designs. System verification runs through the whole design process from specification to implementation, typically with formal methods or simulation-based validation. As the system has become extremely complex, the verification or validation consumes an increasing portion of the product development time. The verification effort has reached as high as 70% of engineering efforts.

Productivity gap [1,4]: Simply put, productivity gap is the gap between what we are capable of building and what we are capable of designing. In line with Moore's law, the logic capacity of a single chip has increased at the rate of 58% per annum compounded. Soon the complexity of the chip enters the billion-transistor era. The complexity of developing SoCs is in creasing continuously in order to exploit the potential of the chip capacity. However, the productivity of hardware and software design is not growing at a comparable pace. The hardware design productivity is increased at a rate in the range 20% to 25% per annum compounded. Even worse, the software design productivity improves at a rate in the range from 8% to 10% per annum compounded. As a consequence, the costs of developing advanced SoCs are increasing at an alarming pace and time-to-market is negatively affected. The design team size is increased by more than 20% per year. This huge investment is becoming a serious threshold for new product developments and is slowing down the innovation in the semiconductor industry. As stated in the ITRS roadmap [1], cost of design is the greatest threat to continuation of the semiconductor roadmap.

## **References:**

- A. P. Galkin, etc. Projecting Network-on-Chip as a System-on-Chip platform for safe information// Indian Science Cruiser. V. 27. No. 6. November 2013. P. 35-38.
- V. Broido, Computer systems, networks and telecommunications. / the textbook for high schools. – Sankt-Peterburg.: Peter, 2008,-768 p.
- 3. A. P. Galkin, etc. Improving fault tolerance computing networks for multihoming//News of institute of engineering physics. 2012.No. 3.P. 22-24.
- 4. A. P. Galkin, etc. Minimization of routers at maintenance of information protection in networks//News of institute of engineering physics. 2013.No. 1.P. 2-4.